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INFORMATION DISCLOSURE	Complete if Known		
STATEMENT BY APPLICANT	Application Number	10/529,369	
	Filing Date	October 5, 2005	
May 29, 2009	First Named Inventor	H. MATSUTANI	
	Art Unit	1796	
(use as many sheets as necessary)	Examiner Name	Marc S. Zimmer	

Attorney Docket Number

of

Sheet

	U.S. PATENT DOCUMENTS						
Examiner	Cite	Document Number		Publication Date	Name of Patentee or	Pages, Columns, Lines, Where	
Initials'	No. <sup>1</sup>			MM-DD-YYYY	Applicant of Cited	Relevant Passages or Relevant	
		Number-Kind Code <sup>2</sup> (if known)			Document	Figures Appear	
		US-					
		US-					
		US-					
		US-					
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FOREIGN PATENT DOCUMENTS						
Examiner Initials'	Cite No. <sup>1</sup>	Foreign Patent Document  Country Code <sup>3</sup> –Number <sup>4</sup> –Kind Code <sup>5</sup> (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T <sup>6</sup>
		JP 2001-338978	12/07/2001	K. Furusawa, et al.		Α
		JP 06-346025	12/20/1994	Y. Yamaho, et al.		Α
		JP 2001-15496	01/19/2001	M. Tsunoda, et al.		Α

NON PATENT LITERATURE DOCUMENTS				
Examine r Initials*				
		Japanese Official Action dated May 12, 2009, for Japanese Application No. 2003-317572.		
		Japanese Official Action dated April 28, 2009, for Japanese Application No. 2003-317568.		
		Y. Uchimaru, et al., "Synthesis, Thin Film Formation and Evaluation of a Low-K Silicon-Borazine Polymer", Polymer Preprints, Vol. 51, No. 12 (2002), pp.3077-3078.	Т	
		H. Kame, "AIST has Developed Low-K Films Using Borazine-Silicon Polymer Material to Demonstrate Low Permittivity of 2.1 or Below", <u>Technology Semiconductor</u> , (2002), pp. 100-101.	Т	

Examiner	Date	
Signature	Considered	

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. 1 Applicant's unique citation designation number (optional). 2 See Kinds Codes of USPTO Patent Documents at www.uspto.gov or MPEP 901.04. 3 Enter Office that issued the document, by the two-letter code (WIPO Standard ST.3). 4 For Japanese patent documents, the indication of the year of the reign of the Emperor must precede the serial number of the patent document. 5 Kind of document by the appropriate symbols as indicated on the document under WIPO Standard ST.16 if possible. 6 Applicant is to place a check mark here if English language Translation is attached.

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